## **EAST Search History**

## **EAST Search History (Prior Art)**

Ref#	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	7922	(micro or direct) with contact with print\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 12:53
L2	241	master same 1	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 12:53
L3	12	(etch\$3 with layer\$1) same 2	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 12:54
L4	142605	(etch\$3 with layer\$1) same step\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 12:58
L5	6	2 same 4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 12:58
L6	514	master same 4	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:00
L7	22	1 and 6	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:00

L8	26792	(mask\$3 or resist or photoresist) same (etch\$3 with layer) same fill\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:06
L9	154	8 same (tft or lcd)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:07
L10	0	9 same stepped	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:07
L11	6	9 and stepped	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:08
L12	2761	substrate with (etching adj layer)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:12
L13	1328	12 same (master or mask\$3 or photoresist\$3 or resist\$3)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:13
L14	63	13 same fill\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:14
L15	42822	pattern\$3 with resist with remov \$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:35

L16	14465	pattern\$3 with resist with (mask \$3 or stencil\$3) with remov\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:35
L17	14465	pattern\$3 with resist with (mask \$3 or stencil\$3) with remov\$3	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:35
L18	40	pattern\$3 with resist with (mask \$3 or stencil\$3) with remov\$3 with master	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2010/05/18 13:36

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